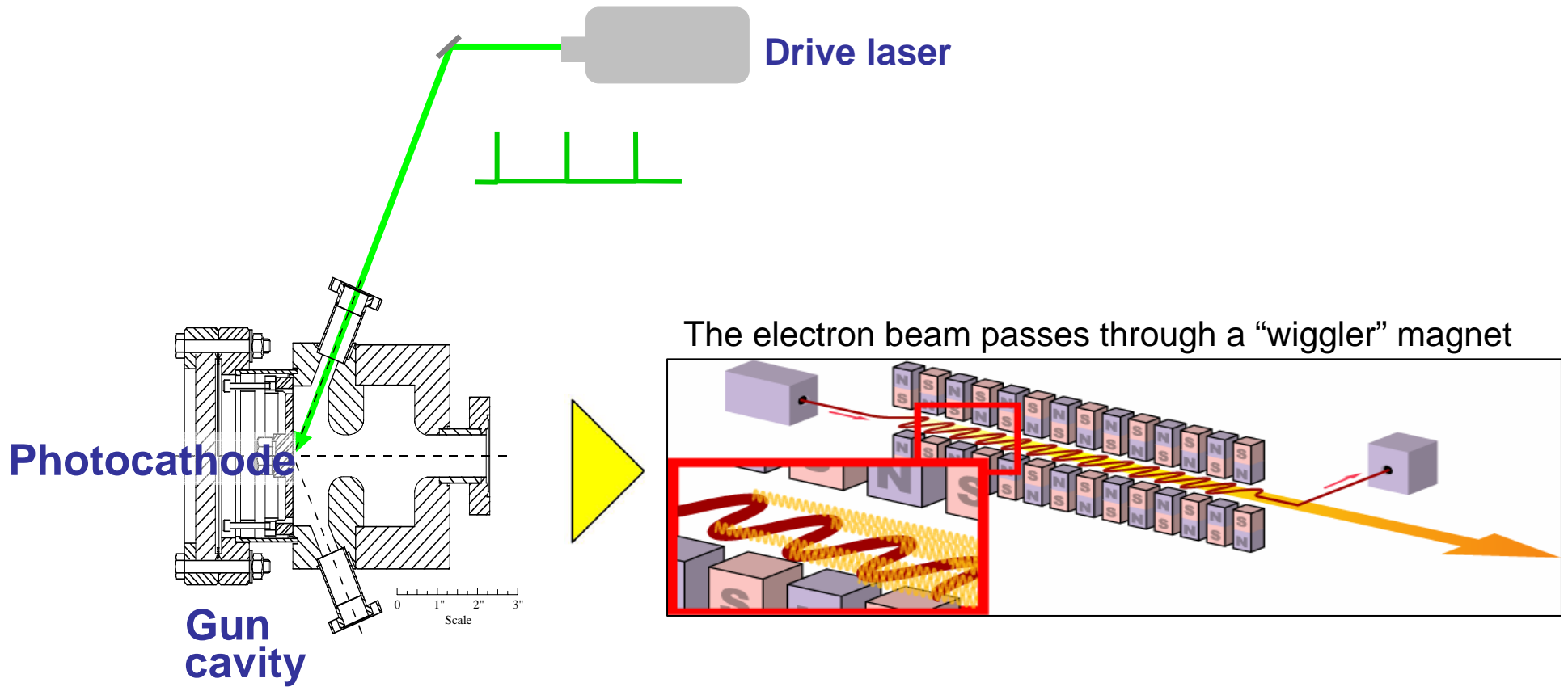
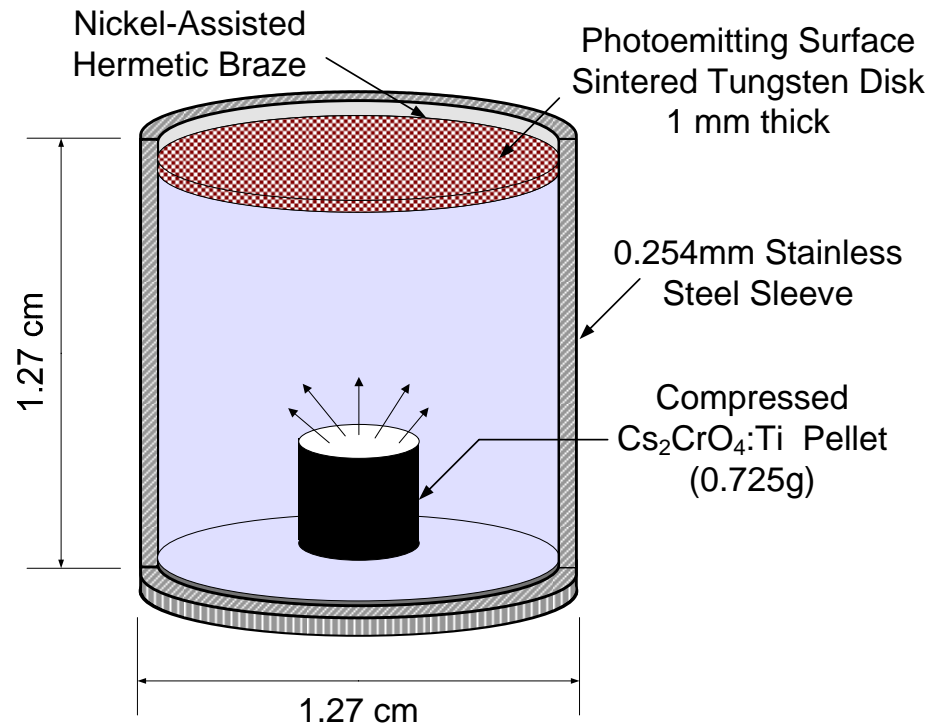
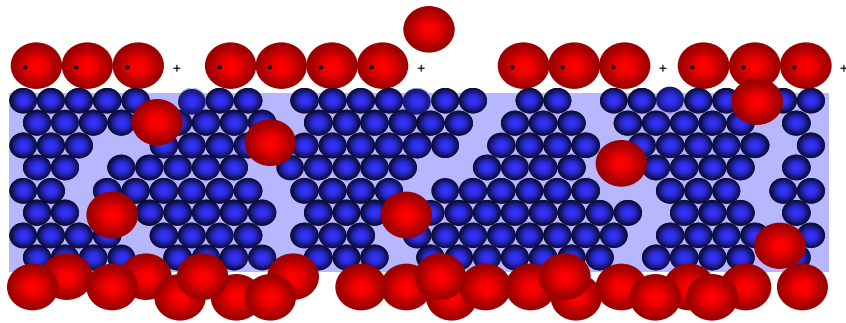


Schematic Overview of a Free Electron Laser



Prototype Dispenser Photocathode

Goal: in-situ re-csesiation



Foundation for Computational Diffusion Model

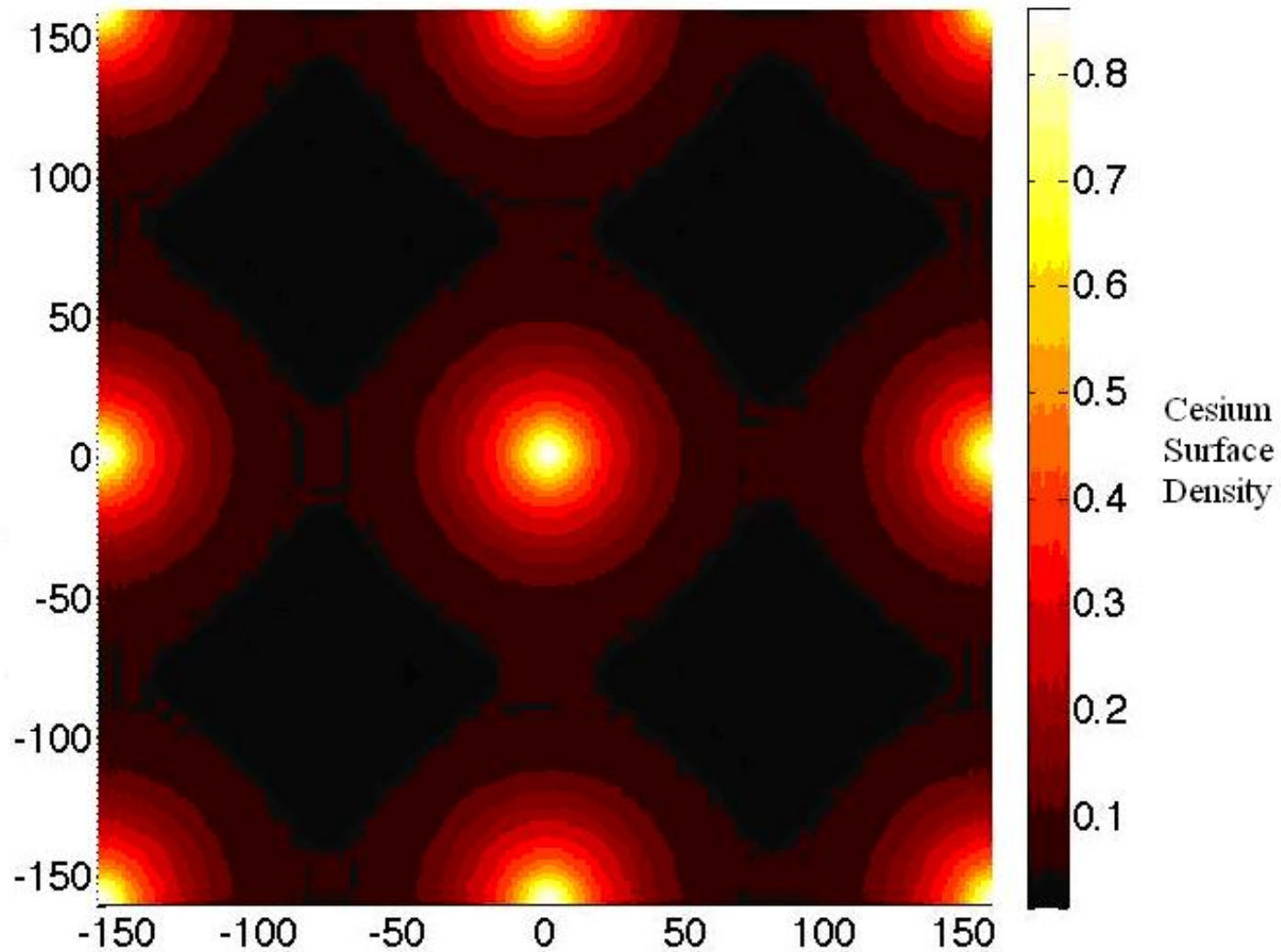
- Cs atoms on the surface of a metal have no preferred direction of diffusion.
- Cs diffuses at the same rate out of each pore of the dispenser.
- Cs atoms stick well to the surface, not to themselves, forming a monolayer or less.
- Coverage of Cs refers not to “thickness” but rather to the percent of one monolayer present on the surface.

$$\phi = -d \cdot u_x$$

Fick's Law of Diffusion

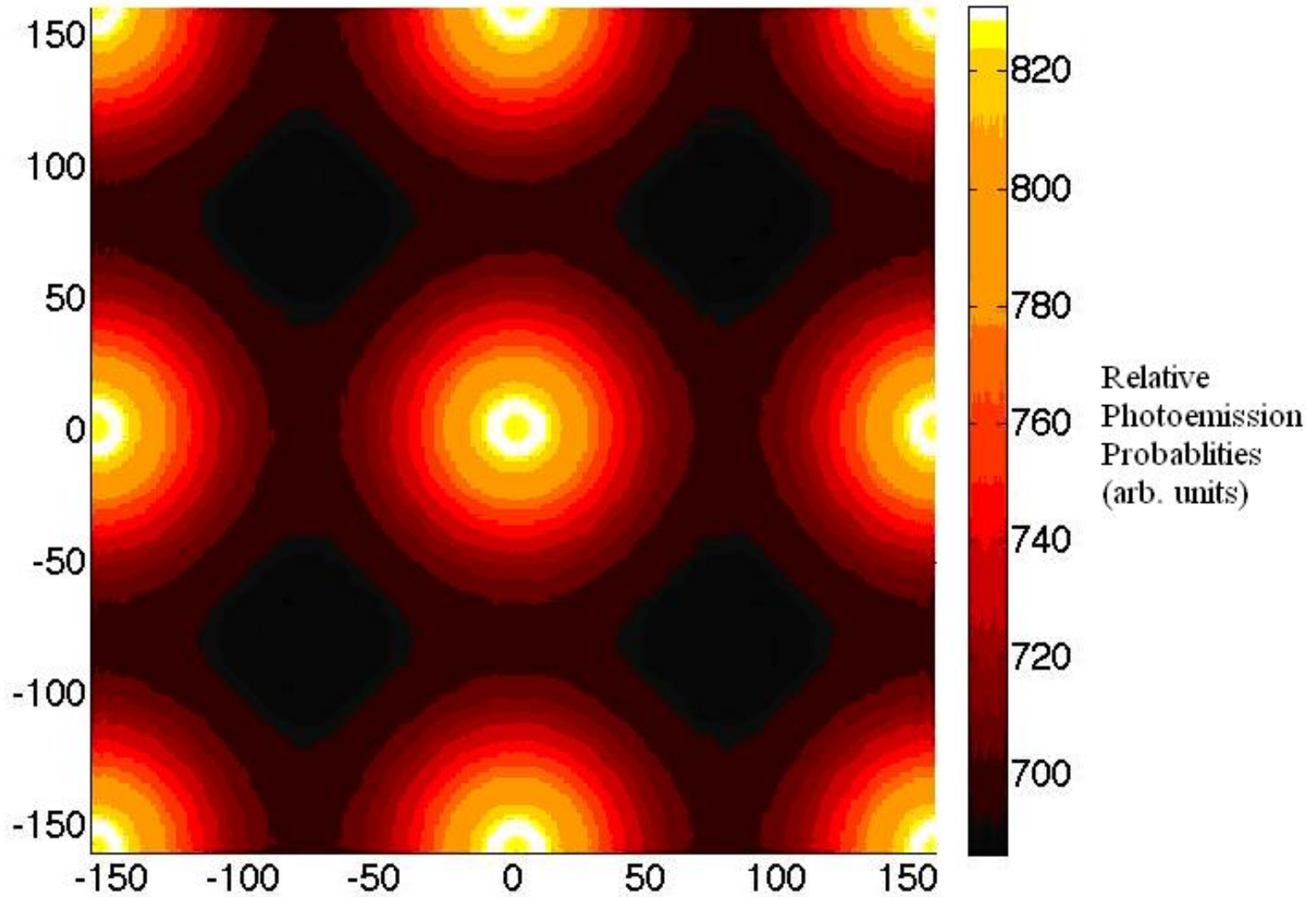
Time Snapshot of Cs Density

Time = 1200 Seconds
Diffusivity = 10 Microns per second
Pore Spacing = 160 Microns



Time Snapshot of Relative Emission Probability

Time = 1200 Seconds
Diffusivity = 10 Microns per Second
Pore Spacing = 160 Microns

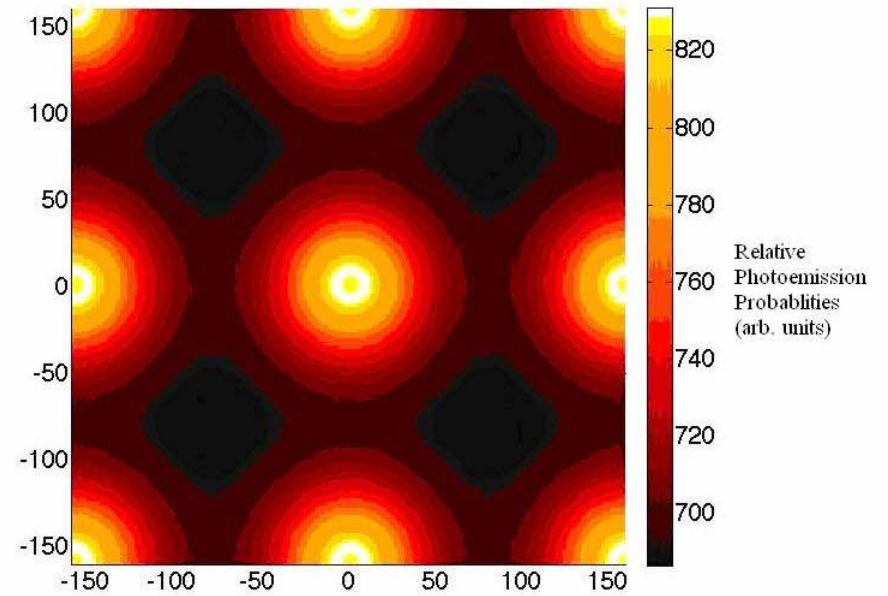
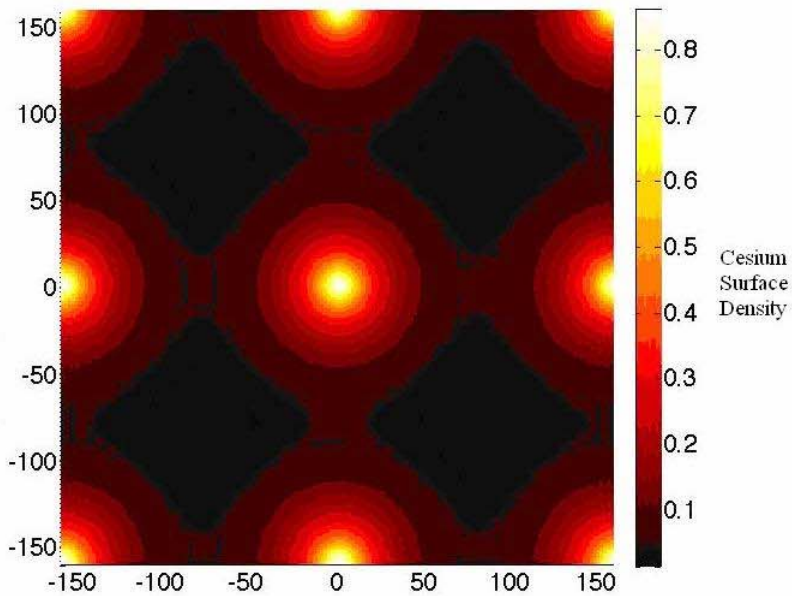


Time Snapshot of Cs Density and Relative Photo-emission Probability

Cs Density

Relative Photo-emission Probability

Time = 1200 Seconds
Diffusivity = 10 Microns per second
Pore Spacing = 160 Microns



Future Work

- Direct experimental data for Cs density over time on a dispenser photocathode is soon to be obtained by collaborators at the Naval Research Laboratory
- Cs evaporation needs to be included in future models
- Validated model will be used to design and optimize a controlled porosity dispenser cathode

